

Application No.: 10/603,924 Docket No.: JCLA7109-R

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re APPLICATION of			
		Shiao-Chung Hu	Examiner: Nguyen, Thanh T.
Serial No.	:	10/603,924	Art Unit : 2813
Filed	:	June 24 th , 2003	Docket No.: JCLA7109-R
For	:	POST-CMP REMOVAL OF SURFACE) CONTAMINATS FROM SILICON) WAFER	

AMENDMENT AND RESPONSE TO OFFICE ACTION

Mail Stop Amendment

Commissioner for Patents P. O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

The Office Action mailed July 11th, 2006 has been carefully considered. In response thereto, please enter the following amendments and consider the following remarks.